

PATENT  
Docket No.: 474082002800

**COMBINED DECLARATION AND POWER OF ATTORNEY  
FOR UTILITY/DESIGN PATENT APPLICATION**

AS BELOW-NAMED INVENTORS, WE HEREBY DECLARE THAT:

Our residences, post office addresses, and citizenship are as stated below next to our names.

We believe we are the original, first and joint inventors of the subject matter which is claimed and for which a patent is sought on the invention entitled:

✓ **HIGH-RESISTANCE SILICON WAFER AND ITS MANUFACTURING METHOD**

the specification of which:

- ☐ is attached hereto.
- ☒ was filed on October 25, 2004, as United States Application Serial No. 10/512,405 or PCT International Application No. \_\_\_\_\_, and was amended on \_\_\_\_\_ (if applicable).

WE hereby state that WE HAVE REVIEWED AND UNDERSTAND THE CONTENTS OF THE ABOVE-IDENTIFIED SPECIFICATION, INCLUDING THE CLAIMS, AS AMENDED BY ANY AMENDMENT REFERRED TO ABOVE.

We acknowledge the duty to disclose information which is material to the patentability as defined in 37 C.F.R. § 1.56.

We hereby claim foreign priority benefits under 35 U.S.C. § 119(a)-(d) or § 365(b) of any foreign application(s) for patent or inventor's certificate, or § 365(a) of any PCT International application which designated at least one country other than the United States listed below and have also identified below, by checking the box, any foreign application for patent or inventor's certificate, or PCT International application having a filing date before that of the application on which priority is claimed:

Application No.	Country	Date of Filing (day/month/year)	Priority Claimed
✓ 2002-127509	Japan	26 April 2002	<input checked="" type="checkbox"/> Yes <input type="checkbox"/> No
✓ 2002-360731	Japan	12 December 2002	<input checked="" type="checkbox"/> Yes <input type="checkbox"/> No
PCT/JP03/04866	Japan	16 April 2003	<input checked="" type="checkbox"/> Yes <input type="checkbox"/> No

We hereby appoint:

All practitioners at Customer Number 25227

all of **Morrison & Foerster LLP**, 2000 Pennsylvania Ave. N.W. Washington D.C. 20006, jointly, and each of them severally, my attorneys at law/patent agent(s), with full power of substitution, delegation and revocation, to prosecute this application, to make alterations and amendments therein, to receive the patent, and to transact all business in the U. S. Patent and Trademark Office connected therewith.

and:

Please mail all correspondence to:

**Kevin R. Spivak**  
**Morrison & Foerster LLP**  
**2000 Pennsylvania Ave. N.W.**  
**Washington D.C. 20006**

Please direct telephone calls to: Kevin R. Spivak at (202) 887-1525.

Please direct facsimiles to: (202) 887-0763.

We hereby declare that all statements made herein of our own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under § 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

1-00

06/06/2005

Date

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06/08/2005

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